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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

OCT 19 2005

Applicant:	Weis, et al.	Docket No.:	02P15178US/ INTECH 3.0-079
Serial No.:	10/774,827	Art Unit:	2822
Filed:	2/9/2004	Examiner:	Michael M. Trinh
Title:	Line Mask Defined Active Areas for 8F2 DRAM Cells with Folded Bit Lines and Deep Trench Patterns		

Date: October 19, 2005

Mail Stop Amendment  
Commissioner for Patents  
P. O. Box 1450  
Alexandria, VA 22313-1450

ELECTION

Dear Sir:

In response to the restriction requirement set forth in the Office Action mailed on September 19, 2005, the Applicant hereby elects Group Ia (claims 7-12) for further prosecution in the above patent application.

Respectfully submitted,



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